Abstract of the Disclosure

In a pattern collation apparatus which collates a registration pattern with a collation pattern, a first collation section executes collation between the registration pattern and the collation

5   pattern on the basis of the correlation value between the patterns. A second collation section executes collation between the registration pattern and the collation pattern on the basis of a feature parameter defined in advance. A collation determination section

10 determines that the registration pattern coincides with the collation pattern by using at least one of the collation results by the first and second collation sections.